**METHOD FOR RADIATION DETECTION AND MEASUREMENT**

Dose of radiation to which a body of crystalline material has been exposed is measured by exposing the body to optical radiation at a first wavelength, which is greater than about 540 nm, and measuring optical energy emitted from the body by luminescence at a second wavelength, which is longer than the first wavelength.
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METHOD FOR RADIATION DETECTION AND MEASUREMENT

Reference to Government Contract

This invention was made with government support under contract number DE-AC06-76RLO 1830, awarded by the U. S. Department of Energy. The government has certain rights in the invention.

Background of the Invention

When a solid-state crystal is exposed to ionizing radiation, several absorption bands make their appearance at increasingly higher levels of radiation damage. In the case of the alkali halides, the F-band is the first of the radiation damage centers to produce a detectable absorption band. With increasing radiation exposure, a second damage center builds up in the absorption spectrum. The second damage center is known as the M-center and is generally thought to consist of two adjacent F-centers. Absorption measurements in LiF indicate that the peak of the M-center absorption occurs at 443 nm.

Highly purified lithium fluoride (LiF) crystals have long been used as optical windows. Optical grade LiF is known for its excellent transmission from the deep ultraviolet through the infrared. LiF crystals have been used for high-level (Mega-Rad) gamma dosimetry using radiation-induced absorption peaks measured with a spectrophotometer. However, absorption measurements are a very insensitive way to measure these radiation damage centers.

Alkali halides have been used to measure the dose of radiation to which crystalline material has been exposed by exciting the crystalline
material with optical radiation at a wavelength that corresponds to that of a known absorption band and observing the luminescence.

Although the F-center provides the greatest concentration of damage centers for a given radiation exposure, the luminescence of the F-center is thermally quenched below room temperature and therefore it is of limited usefulness in quantifying ionizing radiation exposure using luminescence techniques. However, excitation into the longer wavelength M-center absorption band at room temperature produces luminescence. M-center luminescence involves a substantial Stokes' shift, allowing the luminescence to be observed at a significantly different wavelength from the exciting wavelength.

D. F. Regulla, Lithium Fluoride Dosimetry Based on Radiophotoluminescence, Health Physics, Vol. 22, pgs. 491-496 (1972) discloses a dosimetry technique in which luminescence of doped LiF that has been irradiated is excited by light at 450 nm. The luminescence spectrum includes peaks at 520 nm and 620 nm.


In the case of the work reported by Regulla, the LiF that is irradiated is doped. The peak that is reported at 520 nm is not observed with pure LiF. U. S. Patent Application Serial No. 07/431,307, the contents of which are hereby incorporated by reference herein, discloses that radiation damage can be quantified by measuring the M-center
luminescence. The peak of the M-center emission spectrum in LiF occurs at about 665 nm. In accordance with the co-pending application, excitation of an LiF crystal with light at a wavelength that closely matches the wavelength at which the peak of the M-center absorption occurs was found to significantly amplify the luminescence yield of the M-center of LiF.

A disadvantage of the techniques mentioned above is that they require excitation sources that emit light at relatively short wavelengths. Lasers that emit light at such short wavelengths are much more expensive than lasers that emit light in the red and infrared regions.

The applicant is not aware of any published work in which the peak of the M-center absorption band of sodium fluoride (NaF) is reported.

Summary of the Invention

A more sensitive method of measuring radiation damage than absorption measurement can be accomplished by measuring the M-center luminescence. Excitation of an LiF crystal with a 442 nm He-Cd laser has been found to significantly amplify the luminescence yield of the M-center of LiF. An He-Cd laser was the preferred excitation laser because absorption measurements in LiF indicate the peak of the M-center absorption occurs at 443 nm. Laser stimulation produces an excited state of the M-center, which undergoes a very strong Stokes' shift. The peak of the M-center emission spectrum occurs at 665 nm with a half-width of 0.36 ev. Since the excitation wavelength differs significantly from the emission wavelength, measurement of the deep red emission can be done simultaneously.
with the excitation. Therefore, optical filtration provides a means of measuring the M-center luminescence simultaneously with laser excitation into the M-center absorption band. The population of M-centers grows with increasing radiation damage, and therefore M-center luminescence provides a basis for radiation dosimetry. Readout of the LiF can be accomplished in a fraction of a second.

While all members of the alkali halide family are candidates for M-center luminescence dosimetry, lithium fluoride (LiF) was chosen for a number of reasons. First, the crystal is commercially available in large quantities through its use as optical window material. Secondly, LiF is nearly tissue equivalent in its energy response to photons, making it a suitable material for mixed field dosimetry applications. Finally, LiF can be excited by a low cost, commercially available blue-light laser and its M-center luminescence occurs significantly within the visible spectrum. This feature simplifies light detection since phototubes that are sensitive to the visible light spectrum are readily available. Data describing the dosimetric properties of the M-center and other general physical data concerning the M-center are presented in the detailed description, which also discusses the possibilities for M-center dosimetry in LiF.

M-center luminescence exists in almost every solid-state crystal which can be artificially grown at the present time and is not restricted to the alkali halide group. Each crystal has a characteristic M-center absorption band which can be measured following a large radiation exposure (around 1 Mega R). Illumination into the M-center
absorption band with laser light stimulates
M-center luminescence which occurs at a signifi-
cantly different wavelength from the exciting laser
light beam. Easy separation and detection is
possible simultaneously with the exciting light by
using an optical filter which absorbs the exciting
light and transmits the M-center luminescence.

It has been discovered that the M-center
absorption peak of radiation-damaged NaF occurs at
a wavelength of about 500 nm. When irradiated NaF
is excited with light at a wavelength of about 500
nm, it emits light over a range from about 580 nm
to about 750 nm with a peak at about 620 nm. It
has also been discovered that when a body of pure
NaF that has been exposed to ionizing radiation is
excited with light at a wavelength of about 632 nm,
it emits light over a range from about 680 nm to
about 1050 nm with a peak in the luminescence curve
at about 875 nm. Further a body of pure, i.e.
undoped, alkali halide, particularly LiF or NaF,
that has been exposed to ionizing radiation and is
excited by light at a wavelength significantly
longer than that of the peak of the M-center
absorption spectrum emits light in the infrared
region with an intensity that depends on the dose
of radiation to which the body was exposed.

In accordance with a first aspect of the
invention there is provided a method of measuring
radiation dose, comprising exposing a body of
crystalline material to ionizing radiation,
exposing the body to optical radiation at a first
wavelength, which is greater than about 540 nm, and
measuring optical energy emitted from the body by
luminescence at a second wavelength that is longer
than the first wavelength.
In accordance with a second aspect of the invention there is provided a method of measuring dose of radiation to which a body of crystalline material has been exposed, comprising exposing the body to optical radiation at a first wavelength, which is greater than about 540 nm, and measuring optical energy emitted from the body by luminescence at a second wavelength, which is longer than the first wavelength.

In accordance with a third aspect of the invention there is provided a method of measuring radiation dose, comprising exposing a body of crystalline material that undergoes M-center absorption to ionizing radiation, exposing the body to optical radiation at a first wavelength that is significantly longer than that of the peak of M-center absorption, and measuring optical energy emitted from the body by luminescence within a range of wavelengths longer than the first wavelength.

In accordance with a fourth aspect of the invention there is provided a method of measuring dose of radiation to which a body of crystalline material that undergoes M-center absorption has been exposed, comprising exposing the body to optical radiation at a first wavelength that is significantly longer than that of the peak of M-center absorption, and measuring optical energy emitted from the body by luminescence within a range of wavelengths greater than the first wavelength.

In accordance with a fifth aspect of the invention there is provided a method of measuring radiation dose, comprising (a) exposing a body of pure NaF to ionizing radiation, (b) exposing the
body to optical radiation at a wavelength of about 500 nm, and (c) measuring optical energy emitted from the body by luminescence at a wavelength of about 620 nm.

In accordance with a sixth aspect of the invention there is provided a method of measuring dose of radiation to which a body of pure NaF has been exposed, comprising (a) exposing the body to optical radiation at a wavelength of about 500 nm, and (b) measuring optical energy emitted from the body by luminescence at a wavelength of about 620 nm.

In accordance with a seventh aspect of the invention there is provided a method of measuring radiation dose, comprising exposing a body of pure crystalline material that exhibits M-center absorption to ionizing radiation, exciting the material with optical radiation at a first wavelength that is near the peak M-center absorption wavelength of said material, and measuring optical energy emitted from the material by luminescence at a second wavelength that is longer than the first wavelength.

In accordance with an eighth aspect of the invention there is provided method of measuring radiation dose, comprising exposing a body of pure crystalline alkali halide material to ionizing radiation, exciting the material with laser light at a wavelength in the blue region of the optical spectrum, and measuring optical energy emitted from the material by luminescence in the red region of the spectrum.
Brief Description of the Drawings

For a better understanding of the invention, and to show how the same may be carried into effect, reference will now be made, by way of example, to the accompanying drawings in which:

FIG. 1 is a diagram of the M-center luminescence readout system. The He-Cd laser produces 70 mW at 442 nm with a beam diameter of 1 mm. The reader consists of a light tight metal box with a sample drawer for insertion and removal of the LiF crystals. The chamber surfaces are made of a black plastic to reject and shield stray light. An RCA 8852 phototube with a broadband optical interference filter is used to reject the laser light and transmit the M-center luminescence. A personal computer houses a multichannel scaling board for photon counting capable of 50 MHz.

FIG. 2 shows an LiF M-center luminescence optical emission spectrum measured using a Tracor Northern optical multichannel analyzer. The M-center luminescence emission was excited by a 442 nm He-Cd laser. The LiF crystal was given an exposure of 2.6 C/kg using a $^{60}$Co source. The peak of the emission spectrum is 665 nm with a half-width of 0.36 ev.

FIG. 3 shows an optical absorption spectrum for a LiF crystal exposed to 260 C/kg. The optical path length of the LiF crystal was 6 mm. The optical absorption spectrum was taken using a Hewlett-Packard diode array spectrometer. The peak of the absorption spectrum was measured to be 443 nm.

FIG. 4 shows the optical bleaching rate of the M-center luminescence as a function of 442 nm He-Cd laser energy incident upon the crystal. The crystal
used in this figure was exposed to 26 mC/kg. The
time constant for the optical bleaching was found to
be 32 s. The total reduction in M-center luminescent
intensity was 20% for a delivered energy
of 30 J.

FIG. 5 is a schematic diagram of a personnel
dosimeter based on an LiF crystal.

FIG. 6 illustrates the absorption spectrum of
pure NaF that has been exposed to a dose of gamma
radiation of $10^7$ R.

FIG. 7 illustrates the emission spectrum of
pure NaF that has been exposed to gamma radiation
after excitation by light at 514 nm.

FIG. 8 illustrates the emission spectrum of
pure NaF that has been exposed to gamma radiation
after excitation by light at 632 nm, and

FIG. 9 illustrates the emission spectrum of
pure LiF that has been exposed to gamma radiation
after excitation by light at 632 nm.

**Detailed Description**

Optical grade LiF single crystals (6 mm x 6 mm
x 6 mm) were selected for the M-center measurements.
Since an appreciable population of M-centers are
present in commercially available crystals, the
centers are erased by heat treatment. A heat treat-
ment in air at 873 K for 1 h was found satisfactory
in eliminating the M-center background. After heat
treatment, some of the crystals were kept as
controls, while the remainder were exposed to 0.26,
2.6, 26, and 260 mC/kg from a $^{60}$Co source. After
irradiation, the crystals were stored in paper
envelopes to prevent unwanted light exposure.

As shown in FIG. 1, the readout apparatus
consisted of three distinct functional units: a
70 mW He-Cd 442 nm laser 2, a light-tight box 4 that contained the sample chamber 6 and phototube 8, and a photon counting system 10. The He-Cd laser beam was focused to beam diameter of 1 mm at the crystal face and transmitted through the crystal at the centers of two opposite cube faces. To provide the laser excitation light to the crystals, the laser beam path and the sample chamber were made of black plastic which helped shield stray room light and laser scatter. A broadband interference filter 12 centered at 650 nm was chosen to prevent the 442 nm He-Cd laser light from reaching the phototube 8 and to transmit the M-center luminescence. The filter provided a 650 nm peak transmission of 50% and a bandwidth of 70 nm. Transmission of the scattered 442 nm He-Cd laser light was reduced to 0.01% by the filter 12. A 1 mm aperture was placed between the optical filter and the crystal to help reject some of the background light that accompanies the M-center luminescence. The phototube 8 chosen for the experiment was an RCA 8852 with a red-extended multi-alkali photocathode and was mounted at 90° from the axis of the laser beam. This phototube was chosen for its suitability for photon counting and its excellent red response. The photon counting system consisted of a preamplifier, amplifier, discriminator, and a multichannel scaling board housed in a personal computer. The counting system is capable of 50 MHz rates.

Readout consisted of passing the 70 mW laser beam through the sample chamber and into the LiF crystal while simultaneously counting photons with the multichannel scaling board within the computer. A region of interest was chosen which consisted of 400 channels with each channel having a time width
of 50 ms. An integration was performed over the 400-channel region of interest which lasted for 20 s.

FIG. 2 is a LiF M-center luminescence optical emission spectrum measured using a Tracor Northern optical multichannel analyzer. The LiF crystal was given an exposure of 2.6 C/kg using a $^{60}$Co gamma source. The peak of the emission spectrum is 665 nm with a half width of 0.36 ev. This result was used to determine the optimal interference filter to use in the M-center luminescence reader. An optical absorption spectrum for a heavily exposed LiF crystal was measured using a Hewlett Packard diode array spectrometer. This absorption spectrum is shown in FIG. 3. The exposure level for the absorption spectrum was 260 C/kg. To resolve the M-center absorption curve adequately, it was found that 260 C/kg was the minimum exposure that could be used. The absorption curve peaks at 443 nm, which matches the 442 nm line of the He-Cd laser.

The following table shows the M-center response as a function of $^{60}$Co gamma exposure of 0.26, 2.6, 26 and 260 mC/kg.

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<th>Laser Beam Through a 10% Neutral Density Filter</th>
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Two laser power levels were used due to counting saturation of the 260 mC/kg exposure using the full 70 mW of laser power. Within experimental uncertainty, the response follows a linear relationship. The crystals exposed to 0.26 mC/kg gave an integral response that was twice as high as a crystal that received no exposure.

FIG. 4 is a plot of the bleaching rate of the M-center luminescence as a function of time. The crystal was exposed to 26 mC/kg and the laser power was 70 mW delivered for 600 s. The time constant for the bleaching process was found to be 32 s and appears to remain constant over time. For the entire time in which the M-center luminescence was monitored, the total reduction due to bleaching was only 20%.

The time constant associated with the decay of the excited M-center was measured in a straightforward manner. The same readout apparatus that was used for the previous measurements was used in the time-constant measurements. A nitrogen-pumped dye laser was used to excite an irradiated LiF crystal within the readout apparatus, the signal was fed into a Hewlett-Packard digitizing fast storage oscilloscope. The oscilloscope was allowed to average the M-center decay signal until a smooth set of data was obtained. The time constant measured was 70 ns. This appears to be consistent with measurements of the other authors (5,6).

The M-center luminescence in LiF occurs with a time constant on the order of 70 ns. Based on this measurements, each M-center in LiF should be capable of producing around $10^7$ photons per second at saturation. A simple calculation based on the oscillator strength of the M-center in LiF predicts the M-center luminescence saturates with a 442 nm
laser beam at 40 kw. Since the laser used in the present experiment is 70 mW, large gains in the M-center luminescence signal can be achieved by increasing the excitation power, for example, through use of a high intensity argon laser.

Phototubes that record the M-center luminescence must be extremely sensitive to the red-infra-red emission spectrum if a sensitive dosimeter capable of personnel monitoring is to be realized. Unfortunately, red extended phototubes capable of single photon counting have characteristically large dark counts associated with thermionic emission. A commercially available dye laser provides an elegant solution to the problem of high dark counts and also satisfies the need for large peak powers to achieve saturation of the M-center luminescence. Since dye lasers typically have extremely short pulse lengths, the red extended phototube dark count within the duration of the dye laser pulse becomes negligible. The flashlamp-pumped dye laser can be made to produce very large peak powers with time constants of 10 to 100 μs, orders of magnitude longer than the time constant for the decay of excited M-centers. Therefore, through the use of the flashlamp-pumped dye laser, the M-center luminescence is maximized by producing saturation, while allowing a sampling of the luminescence in a time period that is much longer than the decay constant of the M-center. This condition will provide better statistical results. Fortunately, the M-center luminescence yield at saturation is theoretically optimized with the same laser that produces a negligible dark count.

The most restricting aspect of the M-center luminescence technique in LiF is the large
fluorescence background. The unwanted background, stimulated by the direct and scattered laser light, emanates from a number of sources. The first such source is the fluorescence that results within the chamber surfaces from laser light scatter. A careful chamber design both in geometry and in material selection can greatly reduce this source of unwanted light. A second source is the fluorescence that emanates from the crystal surfaces. The surface fluorescence is clearly visible by the human eye under the proper conditions and represents the largest source of unwanted light. The surface fluorescence depends on the nature of the fluorescing species at the surface. The third source of unwanted light is from the bulk of the crystal. Impurities within the crystal that are excited by the laser beam will produce light that interferes with the desired signal. This source of light has not been observed at the present time, due to the large fluorescence signals that mask the bulk crystal effects. The fourth source of background light is from the leakage of the optical filter used both to condition the laser and to block stray laser light from reaching the phototube. Since the phototube is highly sensitive to the exciting laser wavelength, proper filtration is essential. High quality filters and the use of multiple filters may prevent this source of background from causing any serious problems. The final source of background light is perhaps the most troubling.

In the dosimeter application, it is desirable that the dosimeter be reusable, and this implies the need to anneal the crystal so as to remove the M-centers. As noted previously, thermal treatment can be used to eliminate the M-centers. However,
at some point of the heat treatment, the M-center will reach an equilibrium level, at which point further reduction in M-center concentration becomes difficult. It remains to be seen whether this concentration level will be suitably low to perform adequate personnel radiation monitoring.

Based on the foregoing, it will be appreciated that M-center luminescence in LiF using a $^{60}$Co gamma source has been demonstrated to be a useful dosimeter in the exposure range of 0.026 to 260 mC/kg. The major difficulty in using LiF for M-center luminescence dosimetry is the large background of fluorescence which accompanies the M-center luminescence signal. Low cost diode lasers emitting in the infra-red are currently available which could be used to excite those crystals which have their M-center absorption band in the infra-red.

Many alkali halides have their M-center luminescence absorption band in the infra-red. An inexpensive infra-red detector can be used to detect the infra-red luminescence allowing a low cost laser and detection system to be technically feasible. In this way, the M-center luminescence can be used as a means of personnel or environmental dosimetry. By coupling a small infra-red light source with an infra-red detector and suitable optical filters, the combination becomes a radiation monitor which gives a real-time analysis. FIG. 5 illustrates such a dosimeter, comprising a crystal 20 to which are mounted a battery-powered diode light source 22, such as diode laser, a light detector 24, such as an avalanche photodiode, to detect the crystal's M-center luminescence, and an optical filter 26 to
block the laser light and transmit the crystal's M-center luminescence.

Optically stimulated luminescence is described in co-pending U. S. patent applications Serial Nos. 07/213,245, now U. S. Patent 4,954,707, and 07/420,293, now U. S. Patent 5,025,159, the contents of which are hereby incorporated by reference herein.

FIG. 6 illustrates (curve A) the absorption spectrum of pure NaF that has been exposed to a dose of $10^7$ R, and, as a control (curve B), the absorption spectrum of NaF that has not been irradiated. The absorption spectra shown in FIG. 6 were measured using known techniques and conventional equipment. It will be seen that curve A exhibits a peak at about 505 nm. This is the M-center absorption peak. It will also be seen from curve A that, within the measurement domain, there is no significant absorption peak at wavelengths longer than that of the M-center absorption peak.

A single crystal of pure NaF was exposed at room temperature (about 20°C) to gamma radiation from a Co-60 source. A laser light source that emits light at a wavelength of about 510 nm, such as an argon laser that emits at 514 nm, was positioned so that its output light beam was incident on the crystal, and a spectrometer was positioned to receive light emitted from the crystal and measure the intensity of received light as a function of wavelength. The luminescence spectrum that was measured is shown in FIG. 7. The luminescence spectrum has a pronounced peak at about 620 nm.

In another experiment using irradiated single crystals of pure NaF, the argon laser was replaced
by a helium-neon laser that emits light at 632 nm. The luminescence spectrum that was measured is shown in FIG. 8 and ranges from 680 nm to 1050 nm and has a peak in the infrared region at about 875 nm. The amplitude of the peak of the luminescence emission was found to be substantially related to the dose of gamma radiation from approximately 1 R to 100,000 R.

Since FIG. 6 shows that the absorption spectrum of NaF does not have a peak at around 630 nm, the applicant believes that the effect illustrated by FIG. 8 is not highly wavelength dependent, and that excitation of pure NaF with light over a broad range of wavelengths, e.g. from 560-750 nm, would provide an emission spectrum similar to that shown in FIG. 8.

In a similar experiment with LiF, the luminescence spectrum (FIG. 4) ranged from about 650 nm to about 1050 nm and had a peak that is in the infrared region (about 730 nm). Based on the fact that the M-center absorption spectrum of LiF has its peak at about 433 nm, the applicant concludes that excitation of LiF with light at a wavelength from 550-700 nm would provide an emission spectrum similar to that shown in FIG. 9.

The observations described with reference to FIGS. 8 and 9 suggest that luminescence of a radiation-damaged crystalline material, particularly an alkali halide in the pure state, can be excited by lasers that emit light in the red and infrared regions and that such luminescence provides a sensitive measure of gamma radiation dose.

In addition to the increased sensitivity, the technique of stimulating luminescence by excitation with light at a wavelength significantly greater
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therein without departing from the scope of the invention as defined in the appended claims and equivalents thereof. For example, although the observations described above with reference to FIGS. 8 and 9 have been made only on two materials, namely LiF and NaF, it is believed that similar results would be observed with other crystalline materials, particularly other alkali halides.
References


The disclosure of each reference is hereby incorporated by reference herein.
Claims

1. A method of measuring radiation dose, comprising:
   exposing a body of crystalline material to ionizing radiation,
   exposing the body to optical radiation at a first wavelength, which is greater than about 540 nm, and measuring optical energy emitted from the body by luminescence at a second wavelength that is longer than the first wavelength.

2. A method according to claim 1, wherein the material is a pure alkali halide material.

3. A method according to claim 2, wherein said first wavelength is about 630 nm.

4. A method according to claim 2, wherein the alkali halide material is lithium fluoride.

5. A method according to claim 4, wherein the second wavelength is about 730 nm.

6. A method according to claim 2, wherein the alkali halide material is sodium fluoride.

7. A method according to claim 6, wherein the second wavelength is about 875 nm.

8. A method of measuring dose of radiation to which a body of crystalline material has been exposed, comprising:
exposing the body to optical radiation at a first wavelength, which is greater than about 540 nm, and
measuring optical energy emitted from the body by luminescence at a second wavelength, which is longer than the first wavelength.

9. A method according to claim 8, wherein the material is a pure alkali halide material.

10. A method according to claim 9, wherein said first wavelength is about 630 nm.

11. A method according to claim 9, wherein the alkali halide material is lithium fluoride.

12. A method according to claim 11, wherein the second wavelength is about 730 nm.

13. A method according to claim 9, wherein the alkali halide material is sodium fluoride.

14. A method according to claim 6, wherein the second wavelength is about 875 nm.

15. A method of measuring radiation dose, comprising:
   exposing a body of crystalline material that undergoes M-center absorption to ionizing radiation,
   exposing the body to optical radiation at a first wavelength that is significantly longer than that of the peak of M-center absorption, and
measuring optical energy emitted from the body by luminescence within a range of wavelengths longer than the first wavelength.

16. A method according to claim 15, wherein the material is a pure alkali halide material.

17. A method according to claim 16, wherein said first wavelength is about 630 nm.

18. A method according to claim 16, wherein the alkali halide material is lithium fluoride.

19. A method according to claim 18, wherein the second wavelength is about 730 nm.

20. A method according to claim 16, wherein the alkali halide material is sodium fluoride.

21. A method according to claim 20, wherein the second wavelength is about 875 nm.

22. A method of measuring dose of radiation to which a body of crystalline material that undergoes M-center absorption has been exposed, comprising: exposing the body to optical radiation at a first wavelength that is significantly longer than that of the peak of M-center absorption, and measuring optical energy emitted from the body by luminescence within a range of wavelengths greater than the first wavelength.

23. A method according to claim 22, wherein the material is a pure alkali halide material.
24. A method according to claim 23, wherein said first wavelength is about 630 nm.

25. A method according to claim 23, wherein the alkali halide material is lithium fluoride.

26. A method according to claim 18, wherein the second wavelength is about 730 nm.

27. A method according to claim 23, wherein the alkali halide material is sodium fluoride.

28. A method according to claim 20, wherein the second wavelength is about 875 nm.

29. A method of measuring radiation dose, comprising:
(a) exposing a body of pure NaF to ionizing radiation,
(b) exposing the body to optical radiation at a wavelength of about 500 nm, and
(c) measuring optical energy emitted from the body by luminescence at a wavelength of about 620 nm.

30. A method according to claim 29, wherein step (b) comprises exposing the body to optical energy at a wavelength of about 510 nm.

31. A method of measuring dose of radiation to which a body of pure NaF has been exposed, comprising:
(a) exposing the body to optical radiation at a wavelength of about 500 nm, and
(b) measuring optical energy emitted from the body by luminescence at a wavelength of about 620 nm.

32. A method according to claim 31, wherein step (a) comprises exposing the body to optical energy at a wavelength of about 510 nm.

33. A method of measuring radiation dose, comprising:
   exposing a body of pure crystalline material that exhibits M-center absorption to ionizing radiation,
   exciting the material with optical radiation at a first wavelength that is near the peak M-center absorption wavelength of said material, and
   measuring optical energy emitted from the material by luminescence at a second wavelength that is longer than the first wavelength.

34. A method according to claim 33, wherein the crystalline material is an alkali halide material.

35. A method according to claim 34, where the alkali halide material is optical window quality lithium fluoride.

36. A method according to claim 33, comprising exciting the material with coherent optical radiation at said first wavelength.
37. A method according to claim 33, comprising measuring optical energy emitted by luminescence in the visible region of the spectrum.

38. A method according to claim 33, wherein the material is optical window quality lithium fluoride, and the method comprises exciting the material by laser light at a wavelength in the blue region of the optical spectrum and measuring optical energy emitted by luminescence in the red region of the spectrum.

39. A method according to claim 33, comprising exciting the material by use of a laser light source that emits light at said first wavelength at a power level of about 70 mW.

40. A method of measuring radiation dose, comprising:
   exposing a body of pure crystalline alkali halide material to ionizing radiation,
   exciting the material with laser light at a wavelength in the blue region of the optical spectrum, and
   measuring optical energy emitted from the material by luminescence in the red region of the spectrum.

41. A method according to claim 40, wherein the alkali halide material is lithium fluoride.
FIG. 1

442nm He-Cd LASER

PHOTOTUBE 8
OPTICAL INTERFERENCE FILTER 12
SAMPLE DRAWER 6

PERSONAL COMPUTER WITH MULTI-CHANNEL SCALING BOARD 10

SIGNAL TO COMPUTER VIA ELECTRONICS
**FIG. 4**

Graph showing the relationship between laser energy (J) and M-center intensity. The energy ranges from 0 to 30 J on the x-axis, and intensity ranges from 0 to 5,520,000 on the y-axis.

**FIG. 5**

Diagram of a diode laser with a crystal and optical filter. Labeled components include:
- 20 Crystal
- 22
- 24
- 26 Optical Filter
I. CLASSIFICATION OF SUBJECT MATTER

According to International Patent Classification (IPC) or to both National Classification and IPC

Int.C1.5  G 01 T 1/10  G 01 T 1/105

II. FIELDS SEARCHED

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Documentation Searched other than Minimum Documentation to the Extent that such Documents are Included in the Fields Searched

III. DOCUMENTS CONSIDERED TO BE RELEVANT

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<td>WO,A,9106875 (BATTLE MEMORIAL INSTITUTE) 16 May 1991, see abstract; page 2, lines 10-35; page 3, lines 20-33; page 11, lines 4-20; figures (cited in the application)</td>
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<td>A</td>
<td>HEALTH PHYSICS, vol. 29, no. 3, September 1975, Pergamon Press (IE), S. DATTA et al.: &quot;Luminescence dosimetry using sodium fluoride single crystals&quot;, pages 420-421, see the entire article</td>
<td>1, 2, 6, 8, 9, 13, 15, 22, 29, 31, 33, 40</td>
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<td>US,A,4507562 (GASIO ET AL.) 26 March 1985, see column 4, lines 50-68; column 5, lines 13-23; figure 1</td>
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IV. CERTIFICATION

Date of the Actual Completion of the International Search: 21-10-1992

Date of Mailing of this International Search Report: 09. 11. 92

International Searching Authority: EUROPEAN PATENT OFFICE

Signature of Authorized Officer: DATTA
ANNEX TO THE INTERNATIONAL SEARCH REPORT
ON INTERNATIONAL PATENT APPLICATION NO. US 9201468
SA 62346

This annex lists the patent family members relating to the patent documents cited in the above-mentioned international search report. The members are as contained in the European Patent Office EDP file on 05/11/92. The European Patent Office is in no way liable for these particulars which are merely given for the purpose of information.

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For more details about this annex: see Official Journal of the European Patent Office, No. 12/82